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Substitute for form 1449A/PTO		Complete if Known	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Application Number	10/042,142
		Filing Date	01/11/2002
		First Named Inventor	Lin, Wei
		Group Art Unit	2155
(use as many sheets as necessary)		Examiner Name	Baturay, Alicia
Sheet	1	of	1
		Attorney Docket Number	2000-0672 (1014-199)

PUBLISHED U.S. PATENT DOCUMENTS

Examiner Initials	Application or Patent Number	Name of Applicant or Patentee	Date of Publication
	6,118,793	Chen	12 September 2000
	7,068,649	Fisher	27 June 2006
	6,961,344	Gaspar	1 November 2005
	7,310,326	Lin	18 December 2007
	7,035,270	Moore, Jr.	25 April 2006
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	6,252,881	Samoylenko	26 June 2001
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NON-PUBLISHED U.S. PATENT DOCUMENTS

Examiner Initials	Application Number	Name of Applicant	Filing Date
	11/598,575	Lin	13 November 2006
	11/824,364	Lin	11 January 2002

Examiner Signature		Date Considered	
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¹ EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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